

 <b>APPLICANT'S ART CRYSTATION</b> (Use several pages if necessary)		Application <b>10/600,087</b>		OFGS File No. <b>P/289=169</b>			
		Applicant <b>Makoto MARUYA</b>					
		Filing Date <b>June 20, 2003</b>		Group Art Unit			
<b>U.S. PATENT DOCUMENTS</b>							
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate	
	US-						
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<b>FOREIGN PATENT DOCUMENTS</b>							
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
scc	JP-A 8-180206	07-1996	Japan				X
↓	JP-A 10-197244	07-1998	Japan				X
↓	JP-A 11-278400	10-1998	Japan				X
↓	P2002-63580	02-2002	Japan				X
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
scc		Applicant's summarization in English of Japanese patent nos. 8-180206; 10-197244;					
		11-278400 and P2002-63580					
Examiner /Sheela Chawan/		Date Considered 10/02/2006					
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.							